

JC971 U.S. PTO 09/843419

Attorney Docket No.: 002900/D2/EPIC/EPIC/JW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:) Group Art Unit:				
Suketu A. Parikh) Examiner:				
Serial No.: Ne	w Divisional Application)				
Filed:) <u>INFORMATION DISCLOSURE STATEMENT</u>				
For: Techniqu Damascene Fa	es For Triple And Quadruple abrication))))				
Assistant Cor Washington,	nmissioner for Patents D.C. 20231	·				
Sir:						
This Informat	tion Disclosure Statement					
[X]	is filed within three months after the filing date of a national application or three months after the date of entry of the national stage in an international application or before the mailing date of a first office action on the merits, whichever occurs last. 37 C.F.R. § 1.97(b).					
[]	is filed before the mailing date of either (a) a final action under § 1.113 or (b) a notice of allowance under § 1.311, whichever occurs first, and is accompanied by certification as specified in § 1.97(e) or the fee set forth in § 1.17(p). 37 C.F.R. § 1.97(c).					
[]	is filed after the mailing date of either (a) a final action under § 1.113 or (b) a notice of allowance under § 1.311, whichever occurs first, but before the payment of the issue fee, and is accompanied by					

certification as specified in § 1.97(e);
a petition requesting consideration; and
the petition fee set forth in § 1.17(i)(1). 37 C.F.R. § 1.97(d)

Applicant submits herewith patent(s), publication(s), or other information of which applicant is aware, which applicant believes may be material to the examination of this application and in respect of which there may be a duty to disclose. The filing of this information disclosure statement shall not be construed as a representation that a search has been made (37 C.F.R. 1.97(g)), an admission that the information cited is, or considered to be, material to patentability or that no other material information exists. The filing of this information disclosure statement shall not be construed as an admission against interest in any manner. Notice of January 9, 1992, 1135 O.G. 13-25, at 25. Each reference is identified on the attached Form PTO-1449. A copy of each of the references is supplied herewith.

A concise explanation of the items listed on PTO-1449 is:

- [X] not given, since all items are in the English language
- [] given for only some listed non-English language item(s)
- [] given for each listed item, since all are non-English language documents

The following printed publications are referred to in the body of the specification:

U.S. Pat. No.: 5,635,423, to Huang et al. (1997)
Kaanta et al., "Dual Damascene: A ULSI Wiring Technology", VMIC Conference, IEEE, pp. 144-152, Jun. 11-12, 1991

Applicant has become aware of the following printed publications which may be material to the examination of this application:

U.S. Pat. Nos.:

6,143,646, to Wetzel, 2000

6,133,144, to Tsai et al., 2000

6.133,140, to Yu et al., 2000

6,114,234, to Merchant et al., 2000

6,107,204, to Yu et al., 2000

6,103,619, to Lai, 2000

6,057,227, to Harvey, 2000

6,051,881, to Klein et al., 2000

6,017,817, to Chung et al., 2000

6,001,733, to Huang et al., 1999

5,897,369, to Jun, 1999

5,886,411, to Kohyama, 1999

5,759,911, to Cronin et al., 1998

5,741,626, to Jain et al., 1998

5,739,579, to Chiang et al., 1998 5,726,100, to Givens, 1998 5,705,430, to Avanzino et al., 1998 5,691,238, to Avanzino et al., 1997 5,663,101, to Cronin, 1997 5,651,855, to Dennison et al., 1997 5,614,765, to Avanzino et al., 1997 5,592,024, to Aoyama et al., 1997 5,539,255, to Cronin, 1996 5,354,711, to Heitzmann et al., 1994

European Pat. Application Nos.:

EP0911697A, 1999 EP0851483A, 1998 & 1999 EP0680085A, 1995

Girard et al., "Same Level Integration Of Dual Thickness And Pitch Metal", paper presented At the Thin Film Users Group, California Chapter, 11 pages, Oct. 1997, (best copy available is supplied).

Applicant respectfully submits that the invention claimed in the above identified application is patentable over the references known to applicant and disclosed herein.

Respectfully submitted,

Dated: April 25, 2001

Albert J. Dalhuisen Reg. No.: 36,117

ORM PTO-1449 U.S. Department of Commerce Patent and Trademark Office INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Use Several Sheets If Necessary) U.S. Department of Commerce Patent and Trademark Office				002900/D2/EPIC/E Attorney Docket N		Serial No.:	<u> </u>			
				Applicant: Suketu A. Parikh		44.19 P. 19				
				Filing Date:		Group:		*=		
	·			U.S. PATENT DOCUMEN	TS			C971	<u>^</u>	
Examiner Initials		Serial/Patent Number	Issue Date	Applicant/P	atentee	Class	Subclass	Filing D	ate	
	AA	6,143,646	11/7/00	Wetzel		438	637	6/3/97		
	AB	6,133,144	10/17/00	Tsai et al.		438	634	8/6/99		
	AC	6,133,140	10/17/00	Yu et al.		438	624	10/2/98		
	AD	6,114,234	9/5/00	Merchant et al.		438	631	6/23/99		
	AE	6,107,204	8/22/00	Yu et al.		438	694	10/2/98		
	AF	6,103,619	8/15/00	Lai		438	638	10/8/99		
	AG	6,057,227	5/2/00	Harvey		438	626	6/23/97		
	AH	6,051,881	4/18/00	Klein et al.		257	756	12/5/97		
	Al	6,017,817	1/25/00	Cituing et al.		438	637	5/10/99	5/10/99	
	AJ	6,001,733	12/14/99			633	10/1/98			
	AK	5,897,369	4/27/99	Jun		438	629	9/16/96		
	AL	5,886,411	3/23/99	Kohyama		257	774	7/14/97		
<u> </u>			FOREIGN PATENT	OR PUBLISHED FOREIGN	PATENT APPLICATI	ON		Transla	tion	
	Document Number Publication Date		Country / F	Country / Patent Office		Subclass	Yes	No.		
	AZ	0911697A	4/28/99	EP /		G03F	1/00	-	X	
	BA	0851483A	1998 & 1999	EP		H01L21	768		x_	
	BB	0680085A	1995	EP		H01L21	768	-	Х	
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	BC	OTHER DOO Girard et al. "S	CUMENTS (including Arame Level Integration (uthor, Title, Date, Relevant I Of Dual Thickness And Pitch	Pages, Place of Public Metal*, paper preser	nted at the Thin Film U	Jsers Group, Ca	lifornia Cha	apter,	
-	BC Girard et al. "Same Level Integration Of Dual Thickness And Pitch Metal", paper presented at the Thin Film Users Group, C 11 pages, Oct. 1997 BD Kaanta et al., "Dual Damascene: A ULSI Wring Technology", VMIC Conference, IEEE, pp. 144-152, Jun. 11-12, 1991									
		Tradition of only								
Examiner: EXAMINER:				citation if not in conformance	e Considered:	I Include copy of this	form			

FORM PTO-1449 (Modified)		U.S. D Paten	U.S. Department of Commerce Patent and Trademark Office		002900/D2/EPIC/EPIC/JW Attorney Docket No.:		Serial No.: New Appl'n		
INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Use Several Sheets If Necessary) (37 CFR § 1.98(b))			LICANT	Applicant: Suketu A. Parikh					
				Filing Date:		Group:			
101 01113 1.	00(0))			U.S. PATENT DOCUMEN	TS				
Examiner Initials	r Serial/Patent Issue Date		Issue Date	Applicant/Patentee		Class	Subclass	Filing Dat	te
	AM	5,759,911	6/2/98	Cronin et al.		438	622	8/22/95	
	AN	5,741,626	4/21/98	Jain et al.		430	314	4/15/96	
	AO	5,739,579	4/14/98	Chiang et al.		257	635	9/10/96	
	AP	5,726,100	3/10/98	Givens		438	702	6/27/96	
	AQ	5,705,430	1/6/98	Avanzino et al.		437	195	6/7/95	
	AR	5,691,238	11/25/97	Avanzino et al.		437	195	6/7/95	
	AS	5,663,101	9/2/97	Cronin		438	637	2/7/96	
	AT	5,651,855	7/29/97	Dennison et al.		156	636.1	4/1/96	
	AU	5,635,423	6/3/97	Huang et al.		437	195	10/11/94	
	AV	5,614,765	3/25/97	Avanzino et al.		257	774	6/7/95	
	AW	5,592,024	1/7/97	Aoyama et al.		257	751	10/28/94	
	AX	5,539,255	7/23/96	Cronin		257	750	9/7/95	
	AY	5,354,711	10/11/94	Heitzmann et al.		437	182	7/8/93	
			FOREIGN PATENT O	R PUBLISHED FOREIGN	PATENT APPLICATION	ON		T = 1 e	
		Document Number	Publication Date	Country / Patent Office		Class	Subclass	Translation Yes	No No
	<u> </u>	OTHER DOC	UMENTS (including Aut	hor, Title, Date, Relevant F	Pages, Place of Public	ation)			
Examiner	·			Date	e Considered:				
EXAMINE	R:	Initial citation conside with next communica	ered. Draw line through oution to applicant.	citation if not in conformance	e and not considered.	Include copy of this	iom		